



SLOVENSKI STANDARD
SIST ISO 12218:2002
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Grafična tehnologija - Vodenje procesov - Izdelava tiskovne forme za ofsetni tisk

Graphic technology -- Process control -- Offset platemaking

Technologie graphique -- Maîtrise des procédés -- Confection des plaques offset

Ta slovenski standard je istoveten z: ISO 12218:1997

[SIST ISO 12218:2002](https://standards.iteh.ai/catalog/standards/sist/0450dc09-3420-4e34-99bb-9d4ec5610a62/sist-iso-12218-2002)

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ICS:

37.100.01	Grafična tehnologija na splošno	Graphic technology in general
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INTERNATIONAL STANDARD

**ISO
12218**

First edition
1997-08-01

Graphic technology — Process control — Offset platemaking

*Technologie graphique — Maîtrise des procédés — Confection des plaques
offset*

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Reference number
ISO 12218:1997(E)

ISO 12218:1997(E)

Foreword

ISO (the International Organization for Standardization) is a worldwide federation of national standards bodies (ISO member bodies). The work of preparing International Standards is normally carried out through ISO technical committees. Each member body interested in a subject for which a technical committee has been established has the right to be represented on that committee. International organizations, governmental and non-governmental, in liaison with ISO, also take part in the work. ISO collaborates closely with the International Electrotechnical Commission (IEC) on all matters of electrotechnical standardization.

Draft International Standards adopted by the technical committees are circulated to the member bodies for voting. Publication as an International Standard requires approval by at least 75 % of the member bodies casting a vote.

International Standard ISO 12218 was prepared by Technical Committee ISO/TC 130, *Graphic technology*.

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Annex A forms an integral part of International Standard. Annexes B to F are for information only.

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Introduction

During the production of an offset printing plate, a carrier material is coated with a thin radiation-sensitive film. The plate is referred to as pre-sensitized, if it has been produced by a plate manufacturer rather than at the printing site. The radiation-sensitive coating on the offset printing plate may be either positive-acting (for positive polarity films) or negative-acting (for negative polarity films). Some offset printing plates with positive-acting coatings can be used as convertible plates together with negative polarity input material.

During preparation of the offset printing forme, analogue information is transferred from half-tone film to an offset printing plate by means of a contact exposure step with radiation to which the plate coating has been sensitized. Alternatively, offset printing plates may be exposed using optical projection of reflection or transmission copy or by direct writing techniques. While such alternative processes are not covered by this International Standard, many of the principles included may be applied by analogy.

Before the exposure step, the emulsion side of the half-tone film is brought into intimate contact with the sensitized plate coating, usually by means of a vacuum contact frame. The radiation used for the exposure step may contain both diffuse and unidirectional components. The benefit of diffuse radiation is that artefacts like film edges of positive polarity films, scratches and dust particles are not rendered on the plate. However, care is required because diffuse radiation accentuates any artefacts associated with areas where film and plate are out of contact or where the contact is poor.

During the exposure step, the optical spread function of the printing plate and the diffusive component of the radiation cause final detail on a positive-acting printing plate to be reduced in width so that the image elements are somewhat smaller than the original on the film. With negative-acting plates, the same physical phenomena result in fine detail on the plate that is somewhat larger than the original.

After the exposure step but before development, the coating usually shows a colour difference between exposed and unexposed areas.

The development of an offset printing plate normally consists of the removal of the coating in the non-printing areas. These are the exposed areas of a positive-acting plate and the unexposed areas of a negative-acting plate.

The quality of the printing forme produced by the platemaking operation depends in particular on the following process parameters:

- exposure step, especially vacuum conditions (including drawdown);
- chemical composition and temperature of the developer fluid;
- condition of rollers and brushes;

- processing speed (development time);
- finisher condition.

After development, the colour contrast between printing and non-printing areas is usually much greater than before.

Following exposure and processing, baking or post-exposure treatment may be used prior to correction and gumming. The developed offset printing plate is thus transformed into a press-ready offset printing forme. During correction, image elements are deleted (negative correction) or added (positive correction). At the gumming stage, a thin coating of a colloidal solution is applied to the image side of the plate in order to protect the surface and to prevent toning during the printing operation. Baking or post-exposure treatment is a heat treatment which increases the durability of the coating with regard to chemical or mechanical wear.

Determination of the optimum exposure for positive-acting offset printing plates: There are three important considerations.

- a) The exposure should be strong enough for artefacts like film edges and dust particles to not normally show on the offset printing forme.
- b) The exposure should not be so strong that the transfer of fine highlight half-tone dots is impaired.
- c) Since the exposure also determines tone value, which is very important in process control, the exposure should be controlled such that the tone value decrease from the half-tone film to the offset printing forme is constant, irrespective of the offset printing plate type and processing conditions.

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For half-tone screens with screen frequencies of 70 cm^{-1} or less, it has been found in practice that it is possible to meet considerations a) and b) with a single exposure step. The exposure used is appreciably stronger than one which would result in the best possible resolution (but where artefacts would also be rendered). Consideration c) can be met in addition by observing a suitably selected microline reading.

For periodic or non-periodic fine screens which contain image elements of less than $25 \mu\text{m}$ size, conditions a) and b) cannot be met with a single exposure step. Instead, a first exposure step is carried out that yields the best possible resolution or slightly above. During the second exposure step, the subject areas are protected by a so-called burnout mask; an extended exposure removes the artefacts.

For positive-acting printing plates, it has been found that microline targets can be used to define an exposure range which ensures a reproducible tone value decrease from the half-tone film to the offset printing forme. In this range, the tone value decrease from the half-tone film to the printing forme is a linear function of the microline reading; the function depends on the platemaking resolution. For a particular plate, under given exposure and processing conditions, the graph of the positive microline reading over the logarithm of the exposure thus characterizes the tone value dependence on exposure. The slope of the graph is a measure of the rate of tone value change with exposure change. Therefore, a steep slope indicates less exposure latitude than a less steep one.

Microline targets useful for process control of platemaking contain a number of subtargets with graduated linewidths ranging from a few micrometres to several tens of micrometres. As distinct from the targets

used for testing the resolving power in photography, microline targets show line-to-space ratios other than 1:1. Usual ratios are 1:9, 3:5 and 1:4. Within the usual exposure range the microline reading depends very slightly on the line-to-space ratio. It is important to realize that the microline reading depends on the density level between the microlines. It must not be appreciably higher than elsewhere on the control strip film. As an alternative to a division into subtargets of constant linewidth, a single target with microlines of continuously variable linewidth may also be used. Since there can be directional effects during the manufacture of printing plates as well as during plate processing, it is a good plan to average over readings taken at right angles or to use targets with circular microlines. It is important to note that microline readings always refer to the width of the microlines on the film, not to the (unknown) width on the printing forme.

Determination of exposure negative-acting offset printing plates: There are three important considerations.

- 1) The exposure should be strong enough to achieve a sufficient and reliable run length.
- 2) The exposure should not be so strong that there is excessive tone value increase from the half-tone film to the printing forme or that extreme shadow detail is lost.
- 3) The tone value increase from the half-tone film to the offset printing forme should be at a specified level.

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Since the first criterion is overriding, negative-acting offset printing plate exposures usually follow the recommendation of the plate manufacturer, which is expressed as the reading of a continuous-tone step wedge. Once the optimum exposure has been established, microline targets may be used to additionally monitor the consistency of subsequent exposures. They should not be used as the primary exposure determinant.

Some users employ weaker exposures than the manufacturer recommends, in an effort to obtain a desired tone reproduction in automatic processing systems with plates that have long run-length coatings which require more aggressive processing.

With some plates, the run length may be extended by post-exposure or heat treatment. In these cases, the manufacturer may recommend a lower range of allowable exposures and a post-exposure or baking treatment to extend press life. This may result in a lower tone value increase than otherwise.

Apart from its use for determining the exposure of negative-acting offset printing plates, a continuous-tone step wedge may also be used to assess the development process. A useful quantity in this respect is the platemaking gradation; it characterizes the reaction of the plate coating to the amount of radiation under a given processing condition. A change of the platemaking gradation indicates that the processing conditions or the coating have changed.

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Graphic technology — Process control — Offset platemaking

1 Scope

This International Standard establishes unified terminology, test methods and requirements for the process control of the preparation of the offset printing forme.

This International Standard

- applies to pre-sensitized metal plates;
- applies to contact exposures whether in a contact frame, step-and-repeat machine or other automated processor;
- does not apply to optical projection or direct writing techniques, although the principles may be applied by analogy;
- does not apply to non-periodic half-tone screens, although the tone value specifications may be applied by analogy.

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2 Normative references

[SIST ISO 12218:2002](#)

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The following standards contain provisions which, through reference in this text, constitute provisions of this International Standard. At the time of publication, the editions indicated were valid. All standards are subject to revision, and parties to agreements based on this International Standard are encouraged to investigate the possibility of applying the most recent editions of the standards indicated below. Members of IEC and ISO maintain registers of currently valid International Standards.

ISO 5-2:1991, *Photography — Density measurements — Part 2: Geometric conditions for transmission density.*

ISO 5-3:1995, *Photography — Density measurements — Part 3: Spectral conditions.*

ISO 12647-1:1996, *Graphic technology — Process control for the manufacture of half-tone colour separations, proof and production prints — Part 1: Parameters and measurement methods.*

3 Definitions

For the purposes of this International Standard, the following definitions apply. They are given in alphabetical order.

NOTE — For quantities, the preferred unit is given together with the definition. By definition, the unit of so-called dimensionless quantities is 1.

3.1 baking: Heat treatment to increase the durability of the coating with regard to chemical attack or mechanical wear.

3.2 contact exposure step: Process step where an offset printing plate is exposed in intimate contact with a half-tone film.

NOTE — Usually, a vacuum is used in order to achieve an intimate contact.

3.3 continuous-tone step wedge: Linear array of continuous-tone control patches whose transmittance densities are stepped in increments of 0,15 or 0,30.

3.4 control patch: Area produced for control or measurement purposes. [ISO 12647-1]

3.5 control strip: One-dimensional array of control patches. [ISO 12647-1]

3.6 core density (on a half-tone film): Transmittance density in the centre of an isolated opaque image element such as a half-tone dot or line. Unit: 1. [ISO 12647-1]

3.7 exposure: Product of the irradiance and duration of the photochemically active radiation during the exposure process step. Unit: J/m².

NOTE — Instead of the photochemically active (actinic) radiation, any measure for the total energy deposited may be used once the correspondence has been ascertained.

3.8 exposure latitude: Maximum ratio of exposures that produce acceptable results. Unit: 1.

3.9 exposure step: Process step where an offset printing plate is exposed to photochemically active radiation.

3.10 film polarity: Positive if clear and solid areas on the half-tone film correspond to unprinted and solid areas on the print, respectively. Negative if clear and solid areas on the half-tone film correspond to solid and unprinted areas on the print, respectively.

NOTE — Adapted from ISO 12647-1.

3.11 fringe width (of an isolated opaque half-tone dot): Average distance between the density contour lines corresponding to 10 % and 90 % of the minimum core density specified for the printing process under consideration. Unit: µm.

NOTE — Adapted from ISO 12647-1.

3.12 half-tone film: Film for use with a half-tone printing process showing image elements like dots or lines. [ISO 12647-1]

3.13 microline reading: Under given conditions, the minimum width of positive or negative microlines on half-tone film that transfer such that at least 50 % of the length of the microlines is clearly visible on the offset printing forme. The positive microline reading refers to positive microlines (dark lines on light ground) and the negative microline reading refers to negative microlines (clear lines in dark solid) as they appear on the offset printing forme. Unit: µm.

3.14 microline target: Control patch comprising fine positive and negative lines or various but accurately designated widths.

3.15 negative-acting (offset printing) plate: Offset printing plate for use with negative polarity film. [ISO 12647-2]

3.16 offset printing forme: Forme for planographic printing where the printing parts accept and the non-printing parts do not accept printing ink.

NOTE — An offset plate is transformed into an offset printing forme by means of the exposure, development and post-treatment process steps.

3.17 offset (printing) plate: Plane workpiece whose surface has been coated such that an offset printing forme can be produced thereof. [ISO 12647-2]

NOTE — In current usage also known as an offset printing forme.

3.18 out-of-contact phenomenon: Insufficient transfer of image elements from a half-tone film to an offset printing plate as a result of inadequate contact between them.

NOTE — This may be caused by a mechanical object or an air bubble (due to insufficient vacuum drawdown).

3.19 platemaking; preparation of the offset printing forme: Process steps by which an offset printing forme is prepared from an offset printing plate.

3.20 platemaking gradation: Measure of the dependence of the coating thickness on the offset printing forme on exposure. Unit: 1.

3.21 platemaking resolution: Minimum microline reading for both positive and negative microlines that is achievable with a single exposure step. Unit: μm .

NOTES

1 Not to be confused with the term “resolving power” in photography.

2 Sometimes referred to as the optimum resolution.

3.22 positive-acting (offset printing) plate: Offset printing plate for use with positive polarity film. [ISO 12647-2]

3.23 pre-sensitized offset plate: Offset plate whose surface has been coated by the manufacturer with a radiation-sensitive coating.

3.24 reflectance factor (R): Ratio of the measured reflected flux from the specimen to the measured reflected flux from a perfectly reflecting and perfectly diffusing material located in place of the specimen. Unit: 1. [ISO 5-4]

3.25 reflectance factor density¹); reflection density²): The logarithm to the base 10 of the reciprocal of the reflectance factor, R . Unit: 1.

3.26 screen ruling; screen frequency: Number of image elements, such as dots or lines, per unit of length in the direction which produces the highest value. Unit: cm^{-1} . [ISO 12647-1]

3.27 screen width: Reciprocal of screen ruling. Unit: cm . [ISO 12647-1]

3.28 step-and-repeat machine: Apparatus for making automated-contact exposure steps onto an offset plate.

3.29 tone value; dot area (on a print or a printing forme), A : Percentage of the surface which appears to be covered by colorant of a single colour (if light scattering in the print substrate and other optical phenomena are ignored), calculated from the formula:

$$A (\%) = 100 * \left[1 - 10^{-(D_t - D_0)} \right] / \left[1 - 10^{-(D_s - D_0)} \right]$$

where

D_0 is the reflectance factor density of the unprinted print substrate, or the non-printing parts of the printing forme;

D_s is the reflectance factor density of the solid;

D_t is the reflectance factor density of the half-tone.

Unit: Percent.

NOTES

1 Adapted from ISO 12647-1.

2 Also known as apparent, equivalent or total dot area.

3 The synonym “dot area” may be applied only to half-tones produced by dot patterns.

1) International Lighting Vocabulary ([4] in annex F).

2) ISO 5-4.